

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): **Annapragada et al.**

Application Serial No.: **10/712,326**

Filed: **November 12, 2003**

Title: **Minimizing the Loss of Barrier  
Materials During Photoresist  
Stripping**

Group Art Unit: **2813**

Examiner: **Nguyen, Thanh T**

**REQUEST FOR CONTINUED EXAMINATION,  
AMENDMENT AND RESPONSE TO FINAL REJECTION**

MAIL STOP RCE  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir/Madam:

In response to a final rejection mailed May 10, 2007 in the above-referenced patent application, please enter and consider the following amendments and remarks in light of the attached Request for Continued Examination filed under 37 CFR §1.114. Allowance of pending claims 1-21 in view of the following amendments and remarks is respectfully requested.

**Amendments to the Claims** are reflected in the listing of claims which begins on Page 2 of this paper.

**Remarks** begin on page 10.